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Synthesis and properties of superconducting $T'-R_2CuO_4$ (R=Pr, Nd, Sm, Eu, Gd)

Osamu Matsumoto,¹ Aya Utsuki,¹ Akio Tsukada,² Hideki Yamamoto,³ Takaaki Manabe,⁴ and Michio Naito^{1,*}

¹Department of Applied Physics, Tokyo University of Agriculture and Technology, Naka-cho 2-24-16, Koganei, Tokyo 184-8588, Japan

²Geballe Laboratory for Advanced Materials, Stanford University, Stanford, California 94305, USA

³NTT Basic Research Laboratories, NTT Corporation, 3-1 Morinosato-Wakamiya, Atsugi, Kanagawa 243-0198, Japan

⁴National Institute of Advanced Industrial Science and Technology (AIST), Higashi 1-1-1, Tsukuba, Ibaraki 305-8565, Japan

(Received 17 December 2008; published 25 March 2009)

The parent compounds of high- T_c cuprates have long been considered to be antiferromagnetic insulators. In this Rapid Communication, however, we report that superconductivity is achieved in T'- R_2 CuO₄ (R=Pr, Nd, Sm, Eu, Gd). Superconducting T'- R_2 CuO₄ films were synthesized by using metal-organic decomposition. The highest T_c of T'- R_2 CuO₄ is over 30 K, substantially higher than "electron-doped" analogs. Remarkably, Gd₂CuO₄, even the derivatives of which have not shown superconductivity so far, gets superconducting with T_c^{onset} as high as ~20 K. The implication of our results is briefly discussed.

DOI: 10.1103/PhysRevB.79.100508

PACS number(s): 74.72.Dn, 74.25.Dw, 74.62.Bf, 74.78.Bz

The parent compounds of high- T_c cuprates have long been considered to be antiferromagnetic Mott insulators (chargetransfer insulators). For example, La_2CuO_4 with the K_2NiF_4 (abbreviated as T) structure is an insulator with no doubt. R_2 CuO₄ (*R*: rare-earth element) with the Nd₂CuO₄ (abbreviated as T') structure has also been believed to be a Mott insulator since the discovery of "electron-doped" superconductors, $T' - (R, Ce)_2 CuO_4$ in 1989.¹ In this Rapid Communication, however, we report $T'-R_2CuO_4$ to be superconducting. The origin of the sharp contradiction between the past and our results can be traced to impurity oxygen at the apical site. Empirically, apical oxygen (O_{ap}) atoms in T' cuprates play the role of a very strong scatterer as well as a pair breaker.² Therefore the generic phase diagram of the T' cuprates can be reached only after complete removal of O_{ap} atoms. The report along this line was made initially by Brinkmann et al.³ in 1995. They reported that the superconducting (SC) window for $Pr_{2-r}Ce_rCuO_4$ expands by their improved reduction process down to x=0.04. The expanded SC window can be explained by the suppression of O_{ap}-induced antiferromagnetic order. Employing a thin-film process, we also demonstrated that the superconducting range in T'-La_{2-r}Ce_rCuO₄ expands down to x=0.045.⁴ Furthermore, in the previous paper, we reported superconductivity with T_c ~25 K in T'-(La, R)₂CuO₄, which was achieved by state-ofthe-art molecular-beam epitaxy (MBE).⁵ However, there has been a great controversy on the superconducting nature in T'-(La, R)₂CuO₄: band superconductor or electron-doped Mott-Hubbard superconductor due to oxygen deficiencies. One drawback to obtaining a definitive conclusion is that T'-(La, R)₂CuO₄ is difficult to synthesize by bulk processes. Therefore they are not amenable to any measurement of oxygen nonstoichiometry, such as chemical analysis or neutron diffraction. Hence only speculative discussions have been made based on transport measurements, such as Hall coefficient and Nernst signal.^{6,7} This time, we synthesized superconducting $T'-R_2CuO_4$ by metal-organic decomposition (MOD), a rather inexpensive and easy-to-implement thinfilm process. The key recipe to achieve superconductivity in $T'-R_2CuO_4$ is low- P_{O_2} firing followed by subsequent lowtemperature reduction, which, we believe, cleaned up most

of O_{ap} atoms harmful to high- T_c superconductivity.

Superconducting $T'-R_2CuO_4$ thin films were prepared by MOD using R and Cu naphthenate solutions. The details of the synthesis are described in Ref. 8. In brief, the stoichiometric mixture of naphthenate solutions was spin coated on substrates, either SrTiO₃ (STO) (001) or $DyScO_3$ (DSO) (110).⁹ The coated films were first calcined at 400 °C in air to obtain precursors, then fired at 850-900 °C in a tubular furnace under a mixture of O_2 and N_2 , while controlling the oxygen partial pressure (P_{O2}) from 4×10^{-5} atm to 1 atm. Finally the films were "reduced" in vacuum ($<10^{-4}$ Torr $\approx 10^{-7}$ atm) at various temperatures for O_{ap} removal. The thickness of resultant films was typically 500-1000 Å, although it was not easy to determine it accurately. This is because $T'-R_2CuO_4$ is fairly acid resistive and it is difficult to make a steep edge for profilometry. The resultant films are single-phase T' and also single-crystalline as achieved via solid-state epitaxy.⁸

The end-member T' cuprates are semiconducting with standard bulk synthesis, as is well known. In contrast, thin films of these compounds are fairly metallic after "reduction."⁵ This metallic behavior is probably because thin films are advantageous in Oap removal due to a large surfaceto-volume ratio. However, the optimization of postreduction conditions alone is not sufficient to achieve superconductivity in the parent compounds. The key step for superconductivity is to fire films in a low- P_{O2} atmosphere; the aim of which is to minimize the amount of impurity oxygen prior to the postreduction process. Figure 1 shows the effect of $P_{\Omega 2}$ during firing, which compares the resistivity (ρ) of two Sm₂CuO₄ films (A and B): film A fired at 900 °C for 1 h in $P_{\Omega 2}=1$ atm, followed by reduction at 750 °C for 10 min, and film B fired at 850 °C for 1 h in $P_{\Omega 2} = 2.8 \times 10^{-3}$ atm, followed by reduction at 440 °C for 10 min. Film A is metallic down to 180 K with $\rho(300 \text{ K}) \sim 100 \text{ m}\Omega \text{ cm}$, but shows resistivity upturn at lower temperatures. By contrast, film B is completely metallic with $\rho(300 \text{ K}) \sim 900 \ \mu\Omega \text{ cm}$ and shows superconductivity at $T_c^{\text{net}} = 28 \text{ K} (T_c^{\text{end}} = 25 \text{ K}).$ The dramatic effect of low- P_{O2} synthesis is actually corroborated from the structural aspect. The c-axis lattice constant (c_0) are 11.97 Å for film A and 11.94 Å for film B. The c_0



FIG. 1. Temperature dependences of resistivity for Sm₂CuO₄ films (A and B) on SrTiO₃(001) substrates. Film A was fired at 900 °C for 1 h in P_{O2} =1 atm followed by reduction at 750 °C for 10 min, whereas film B was fired at 850 °C for 1 h in P_{O2} =2.8×10⁻³ atm followed by reduction at 440 °C for 10 min.

of film A shows a good agreement with the bulk value,¹⁰ whereas the c_0 of film B is substantially (~0.03 Å) shorter. Taking account of the well-established trend that the c_0 increases with the amount of O_{ap} atoms,¹¹ our experimental results indicate that low- P_{O2} synthesis is quite effective in preventing O_{ap} atoms from being introduced to lattice.

Figures 2 show the reduction condition dependence of the



FIG. 2. Reduction dependence of ρ -*T* for Pr₂CuO₄ films on DyScO₃(110) substrates: (a) varying the reduction temperature ($T_{\rm red}$) with the reduction duration ($t_{\rm red}$) fixed at 10 min and (b) varying $t_{\rm red}$ with $T_{\rm red}$ fixed at 450 °C. The films were fired with identical conditions (850 °C for 1 h in $P_{\rm O2}$ =2.8×10⁻⁴ atm).



FIG. 3. Plots of T_c and $\rho(300 \text{ K})$ versus c_0 for all Pr_2CuO_4 films on DyScO₃(110) substrates prepared by MOD. Upper (T_c vs c_0): open and filled circles stand for T_c^{onset} and T_c^{end} . Lower [$\rho(300 \text{ K})$ vs c_0]: crosses stand for films not showing superconductivity, filled and open circles stand for films showing superconductivity with and without zero resistance, respectively. Data A–F are from the corresponding films in Fig. 4.

film properties for Pr_2CuO_4 films. The data were taken from the films fired with identical conditions (850 °C for 1 h in $P_{\rm O2}$ =2.8×10⁻⁴ atm) but reduced differently, namely, either with a different reduction temperature (T_{red}) for Fig. 2(a) or a different duration (t_{red}) for Fig. 2(b). The "as-grown" film (not shown) is semiconducting $(d\rho/dT < 0)$ and shows no superconductivity. As shown in Fig. 2(a), the reduction with $T_{\rm red}$ =420 °C and $t_{\rm red}$ =10 min is sufficient for the film to be superconducting ($T_c^{\rm onset} \sim 30$ K). Increasing $T_{\rm red}$ up to 450 °C lowers the resistivity and sharpens the superconducting transition. A further increase in $T_{\rm red}$, however, deteriorates the film properties. Similar behavior is observed in Fig. 2(b) by varying t_{red} with T_{red} fixed at 450 °C. A long transition tail appears already with $t_{red} = 15$ min and superconductivity disappears with $t_{red}=60$ min although there is almost no trace of decomposition as judged from the XRD pattern. It is most likely that excessive reduction leads to loss of oxygen atoms (O1) in the CuO_2 planes, as suggested from the oxygen nonstoichiometry experiments.¹² The reduction with $T_{\rm red}$ =450 °C and $t_{\rm red}$ =5-10 min provides Pr₂CuO₄ (T_c^{onset}) films with optimal properties, highest T_c =31.5 K, $T_c^{\text{end}}=27.3$ K) and lowest resistivity



FIG. 4. Reduction dependence of R_H for Pr_2CuO_4 films. The films are labeled from A to F according to the reduction strength, which are indicated in Fig. 3. R_H goes up with the change in sign from negative to positive with reduction.

 $[\rho(300 \text{ K}) \sim 400 \ \mu\Omega \text{ cm} \text{ and } \rho(T_c^+) \sim 50 \ \mu\Omega \text{ cm}]$. The low resistivity value, which is only about twice as high as our best MBE-grown $Pr_{1.85}Ce_{0.15}CuO_4$ films,¹³ guarantees the high quality of MOD films.

It is difficult to make a quantitative evaluation of the amount of O_{ap} atoms remaining in thin films, but we have found that one good measure for it may be c_0 . Figures 3 plot the $\rho(300 \text{ K})$ (lower) and T_c (upper) as a function of c_0 for all of our MOD-grown Pr_2CuO_4 films. We divide a range of c_0 into three regions:

(I) Insufficient reduction (12.23 Å $\ge c_0 \ge 12.20$ Å). The $\rho(300 \text{ K})$ drops rapidly as c_0 decreases from the bulk value (broken line). Superconductivity with $T_c^{\text{onset}} \sim 25 \text{ K}$ suddenly appears for $c_0 < 12.22$ Å. Decreasing c_0 further toward 12.20 Å, the T_c^{onset} gradually increases to $\sim 30 \text{ K}$, and the T_c^{end} also improves.

(II) *Optimal* reduction (12.20 Å \ge $c_0 \ge$ 12.19 Å). The $\rho(300 \text{ K})$ still decreases as c_0 decreases, and superconductivity becomes optimum.

(III) Excessive reduction (12.19 Å $\ge c_0 \ge 12.16$ Å). The T_c^{onset} starts to drop and the superconducting transition becomes broad with T_c^{end} below 4.2 K, although $\rho(300 \text{ K})$ still decreases until $c_0 \sim 12.18$ Å. With a further decrease in c_0 below 12.18 Å, $\rho(300 \text{ K})$ gradually increases and superconductivity eventually disappears.

At first, it should be pointed out that there is no highly insulating state corresponding to a Mott insulator by reduction starting from the as-grown state containing O_{ap} . Figures 2 and 3 can be explained by assuming that the two effects, namely, O_{ap} removal and O1 loss, are involved in the reduction process. The predominant effect in region (I) is O_{ap} removal, which improves the film properties. In contrast, the predominant effect in region (III) is O1 loss, which degrades the film properties, although O_{ap} may be removed further as judged from the shrinkage of c_0 . The O_{ap} removal is slightly quicker than the O1 loss, which results in O_{ap} atoms mostly cleaned up but with O1 atoms mostly preserved, and provides a stage potential for high- T_c superconductivity.

Figure 4 shows the Hall coefficient (R_H) of Pr_2CuO_4 films. The films are labeled from A to F according to the reduction strength, as correspondingly indicated in Figs. 3. The R_H changes sign with reduction: negative for insuffi-

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TABLE I. Comparison of T_c between R_2 CuO₄ and $R_{1.85}$ Ce_{0.15}CuO₄. T_c 's of $R_{1.85}$ Ce_{0.15}CuO₄ are taken from Ref. 18.

R	$T_c ext{ of } R_2 ext{CuO}_4 ext{ (K)}$	$T_c \text{ of } R_{1.85} \text{Ce}_{0.15} \text{CuO}_4$ (K)
La		18.5 ^a
Pr	31.5	25.0
Nd	32.5	24.0
Sm	27.5	19.0
Eu	27.5	12.0
Gd	19.0	0

^aThe highest T_c of La_{2-x} Ce_xCuO_4 is 30.5 K at x=0.08 (Ref. 4).

ciently reduced films and positive for excessively reduced films. The optimally reduced film (film C) has nearly $R_H \sim 0$. The data in Fig. 4 qualitatively resembles the reduction dependence of R_H in "optimally doped" T'-Nd_{1.85}Ce_{0.15}CuO₄ reported by Jiang *et al.*,¹⁴ especially from the fact that R_H goes up and changes sign from negative to positive with reduction. In general, the Hall coefficients in metals are a very complicated function of anisotropic Fermi velocity as well as anisotropic relaxation time, which makes the interpretation nonstraightforward.¹⁵ The simplistic twoband model, although neither quantitative nor realistic, gives some insight for the sign change of R_H ,

$$R_H = \frac{\mu_p \sigma_p - \mu_n \sigma_n}{(\sigma_p + \sigma_n)^2} = \frac{p e \mu_p^2 - n e \mu_n^2}{(p e \mu_p + n e \mu_n)^2}$$

where *p* and *n* are the carrier densities, μ_p and μ_n the mobilities, σ_p and σ_n the conductivities of hole and electron bands. Based on this model, the behavior of R_H in Fig. 4 can be interpreted as follows. We assume that the majority carriers are hole and the minority carriers are electron and also that O_{ap} scatters mainly hole carriers, which is consistent with the recent analytical papers on the transport properties of $Pr_{2-x}Ce_xCuO_4$ films.^{16,17} With a fair amount of O_{ap} atoms (insufficiently reduced films), the hole mobility μ_p is low and R_H is determined by the minority carriers, namely, negative. By cleaning up O_{ap} atoms, the hole mobility μ_p improves and R_H becomes positive and approaches $\frac{1}{p_e}$. The observed R_H of film D to F is $5-10 \times 10^{-10}$ m³/C, which gives *p* of $1.25-0.625 \times 10^{22}$ holes/cm³, amounting to 1.2-0.6 holes/Cu, namely, almost half filled.

Table I is a summary of the *R* dependence. All *R*'s we have tested show superconductivity except for R=La, which does not form the *T'* structure by MOD.¹⁹ It should be noted that T_c of $T'-R_2CuO_4$ is substantially higher than T_c of $T'-R_{1.85}Ce_{0.15}CuO_4$. The highest T_c^{onset} is 32.5 K in Nd₂CuO₄. The most remarkable is Gd₂CuO₄: there has been no report²⁰ that Gd_{2-x}Ce_xCuO₄ becomes superconducting, whereas Gd₂CuO₄ in the present study has T_c^{onset} as high as 19.0 K.

The key question is the nature of superconductivity in T'- R_2 CuO₄. What one can imagine most easily may be electron-doped Mott-Hubbard superconductivity due to the oxygen (O2) deficiency in the fluorite R_2 O₂ layers, especially when one sees the resemblance of the reduction dependence

in the present paper with the well-known Ce-doping dependence. However, the O2 deficiency in the fluorite R_2O_2 planes is unlikely to occur, especially at temperatures as low as 400 °C, since solid-state chemistry tells us that the R-O bond is much stronger than the Cu-O bond.²¹ In fact, there is no neutron-diffraction experiment^{12,22,23} showing any change in the O2 occupancy with reduction, even though some early experiments showed that the O2 occupancy is not full (namely, slightly below 2.00). This indicates that the reduction dependence of physical properties in T'- R_2 CuO₄ cannot be explained by the change in the O2 occupancy. Furthermore the observation of a positive Hall coefficient with reduction may also argue against a simple electron doping mechanism via O2 deficiency. The physics behind the observation of superconductivity in $T'-R_2CuO_4$ at present is not yet fully understood. However, the amount of O_{ap} atoms seems to affect the phase diagram severely and even the occurrence of the "Mott-Hubbard"- type insulating state.

In summary, we achieved superconductivity in

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T'- R_2 CuO₄ (R=Pr, Nd, Sm, Eu, Gd), which have been believed as a Mott insulator. The highest T_c of T'- R_2 CuO₄ is over 30 K, substantially higher than electron-doped analogs. Our results alert further experiments to establish the nature of superconductivity, especially the oxygen chemistry in T'cuprates. Since MOD is not fundamentally different from bulk synthesis, superconducting T'- R_2 CuO₄ may be obtainable in bulk form, which enables oxygen nonstoichiometry measurements such as chemical analysis and neutron diffraction.

The authors thank Y. Krockenberger and J. Shimoyama for stimulating discussions. The work was supported by KAKENHI B (Grant No. 18340098) from Japan Society for the Promotion of Science (JSPS). O.M. is supported by the "Kagaku-Rikkoku" program sponsored by the Ministry of Education, Science, Sports, Culture, and Technology via Tokyo University of Agriculture and Technology.

- *Corresponding author; FAX: +81 42 385 6255; minaito@cc.tuat.ac.jp
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